

IN THE CLAIMS

Cancel claim 3, and amend claims 1 and 2 as follows:

1. (Once Amended) A dry etching apparatus for treating a body comprising:
 - a chamber;
 - a holder in said chamber to receive a body to be treated;
 - means for introducing gas into said chamber;
 - means for exhausting said gas in said chamber;
 - a power supply of Ultra High Frequency;
 - an electromagnetic wave radiation antenna coupled to said power supply and installed in an atmosphere; and
 - a separation plate used as dielectric between said antenna and the inside of said chamber.

2. (Once Amended) A dry etching apparatus according to claim 1, wherein said separation plate is quartz disk.

REMARKS

Claim 3 has been canceled. Claims 1 and 2 have been amended. Accordingly, claims 1, 2 and 4-33 are currently pending in the application, of which, claims 10-33 have been withdrawn from consideration by the Examiner.

The rejection of claim 3 under 35 U.S.C. § 112, second paragraph, has been rendered moot by the cancellation of that